## Crystal Growth and Property Tuning of Topological Quantum materials



Science

Graduate School & International Education Student: Krishna Pandey Degree: Ph.D., December 2022 Materials Science & Engineering Major Professor: Dr. Jin Hu Nanoscale Materials & Devices Approach **Background/Relevance** Grow single crystals using chemical vapor • Moore's law became challenging below 10nm due to emerging quantum effects. transport and flux methods. Topological quantum materials with exotic properties are Structural and elemental characterization • promising for electronic, optoelectronic, and spintronic devices. using x-ray diffraction (XRD) and energy Innovation dispersive spectroscopy (EDS). Observe the symmetry-protected electronic states of in Dirac Characterize the electronic properties of ٠ Schematic of CVT growth nodal-line semimetal of ZrSiS-family. the topological Dirac fermions in single crystal. Tuning the exotic properties of the materials. Tune the lattice and composition of the material; characterize the • evolution of the Dirac states using resistivity, Hall effect, and guantum oscillation measurements. **Conclusions Key Results** Single crystals of Dirac nodal-line semimetal are synthesized by Successful growth of ZrXY (X=Si, Ge; Y=S, Se Te), LnSbTe (Ln=La, Ce, Gd, Sm, Pr, Nd) single crystals using chemical vapor chemical vapor transport and flux method. transport and flux method. SmSbTe, NdSbTe materials are antiferromagnetic and PrSbTe and • Magnetization, Heat capacity measurement shows the AFM LaSbTe does not have magnetic transition till 2K. ground state with enhanced electronic correlation in NdSbTe **Future Work** and SmSbTe. • Tune the properties of ZrXY and LnSbTe using magnetic field and Collaborative ARPES study shows the topological Dirac States in strain. SmSbTe. Characterize the evolution of the Dirac states using resistivity, Hall • effect, and quantum oscillation measurements. £1.0 C/T (J/mol K<sup>2</sup>) nol Extend area of research to the other materials showing similar • 50.5 properties. Office of **SmSbTe** NdSbTe 10 15 20 T(K) 25 30 10 15 T(K)